



SDI Review Form 1.6

Journal Name:	International Research Journal of Pure and Applied Chemistry
Manuscript Number:	Ms_IRJPAC_20775
Title of the Manuscript:	Preparation of ternary (Ni₃Pb₂S₂) thin films by chemical bath deposition method
Type of the Article	

General guideline for Peer Review process:

This journal's peer review policy states that **NO** manuscript should be rejected only on the basis of '**lack of Novelty**', provided the manuscript is scientifically robust and technically sound.

To know the complete guideline for Peer Review process, reviewers are requested to visit this link:

(<http://www.sciencedomain.org/page.php?id=sdi-general-editorial-policy#Peer-Review-Guideline>)



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PART 1: Review Comments

	Reviewer's comment	Author's comment (if agreed with reviewer, correct the manuscript and highlight that part in the manuscript. It is mandatory that authors should write his/her feedback here)
<u>Compulsory</u> REVISION comments	1. Author has not cleared that aim or scope of above said thin films in respect of application (authors interest in application). Mention application to be carried out. 2. Structural study (XRD) of deposited thin films not included in M/S. 3. How preparative parameters are finalised. [like temp. range, Molarity of solution, pH etc]?	
<u>Minor</u> REVISION comments		
<u>Optional/General</u> comments		

Reviewer Details:

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